

December 7, 2000. Applicants respectfully request that claims 1-35 be canceled  
(pursuant to the amendment below) before calculation of the filing fee.

**IN THE TITLE**

Please replace the current title, " Diagonal Wiring Architecture For Integrated Circuit" with "Simulating Diagonal Wiring Directions Using Manhattan Directional Wires."

**CROSS REFERENCE TO RELATED APPLICATIONS**

This application is a continuation application of United States Patent Application Ser. No. 09/681,776, entitled "Diagonal Wiring Architecture For Integrated Circuit", filed on June 3, 2001, which is a continuation application of United States Patent Application Serial No. 09/733,104, entitled "Multi-Directional Wiring On A Single Metal Layer", filed on

December 7, 2000.

**IN THE SPECIFICATION**

Please delete paragraphs [0004], [0005], and [0006].

*a*

## SUMMARY OF THE INVENTION

Diagonal wiring directions in integrated circuits are simulated with wires deposited in purely Manhattan directions (e.g., horizontal and vertical directions). A metal layer of an integrated circuit contains at least two pairs of conductors to interconnect one or more points on the integrated circuit. As used herein, a conductor comprises one or more wires, and a wire comprises a continuous segment deposited in a single direction. Each pair of conductors, used to simulate the wiring direction, includes two wires. The first wire, which has a first wire length with first and second ends, is deposited in a first Manhattan direction relative to the boundaries of the integrated circuit. The second wire, which has a second wire length with first and second ends, is deposited in a second Manhattan direction, and is coupled to the second end of the first wire. The first Manhattan direction is different than the second Manhattan direction. The effective wiring direction of the pairs of conductors comprises an angle, A, measured relative to the boundaries of the integrated circuit. Specifically, the effective wiring direction is defined by the expression  $\tan A = Y/X$ , wherein, Y defines a line segment with a distance that starts from the second end of the second wire in the last conductor pair and ends at an intersection with a line segment propagated from the first end of the first wire and in the direction of the first wire, and X comprises a distance, measured in the direction of the first wire, that starts from the first end of the first wire and ends with the intersection of the Y line segment.